

Estimation of Iron Concentration in Silicon Solar Cell by Kinetics of Light-Induced Change in Short-Circuit Current

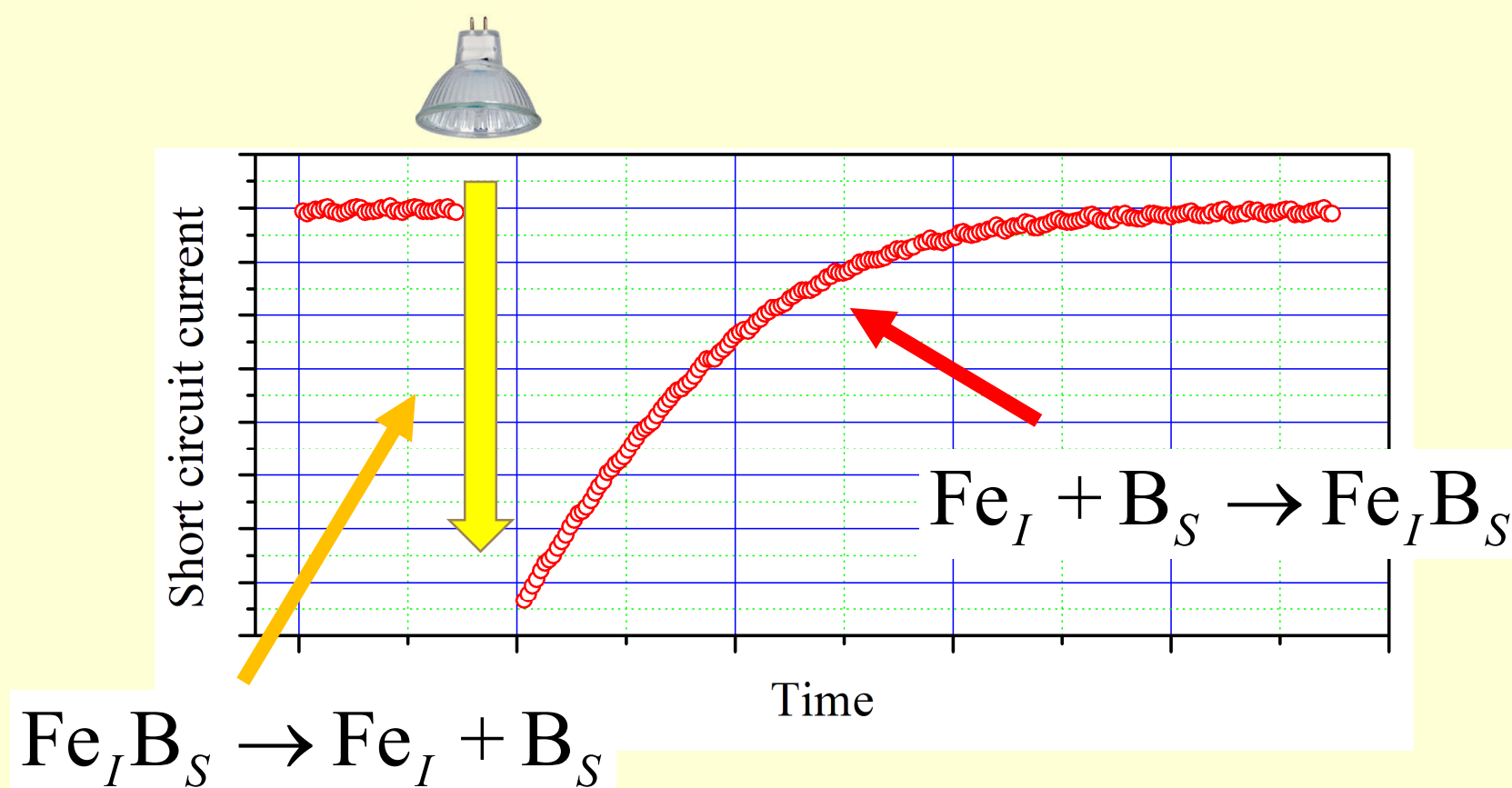
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Introduction. Metal contamination control remains an important challenge for silicon processing both for microelectronics, logic technologies and solar cells (SCs). Typically, metal related defect characterization is performed by Fourier-transform infrared spectroscopy, electron-paramagnetic resonance, minority carrier lifetime measurements, deep level transient spectroscopy (DLTS), Laplace DLTS etc. However, these techniques are time-consuming, require special equipment or/and sample preparing. At the same time, the current-voltage (IV) measurement is a standard rapid industrial SC characterization technique. The proposed approach bases on short circuit current measurements, envisages the utilization of a simple and widely applicable setup and does not require a much time.

IDEA and CALCULATIONS



$$I_{SC} = \frac{W_{ph}(1-R)q\beta\lambda}{hc} \frac{\alpha\sqrt{D\tau}}{1+\alpha\sqrt{D\tau}}$$

$$\frac{1}{\tau} = \frac{1}{\tau_{BtB}} + \frac{1}{\tau_{Auger}} + \frac{1}{\tau_{Fei}} + \frac{1}{\tau_{FeB}} + \frac{1}{\tau_{rest}}$$

$$\tau_{SRH}^{Fei, FeB} = \frac{\tau_{p0}(n+n_1) + \tau_{n0}(N_A+p_1)}{N_A+n}$$

$$\tau_{n,p0} = \frac{1}{N_d \sigma_{n,p} v_{th,n,p}}$$

$$N_{Fe}(t) = (N_{Fe,0} - N_{Fe,eq}) \exp\left(-\frac{t}{\tau_{ass}}\right) + N_{Fe,eq}$$

$$N_{Fe,eq} = \frac{N_{Fe,0}}{\left[1 + N_A 10^{-23} \exp\left(\frac{0.582}{kT}\right)\right] \left[1 + \exp\left(\frac{E_F - 0.394}{kT}\right)\right]}$$

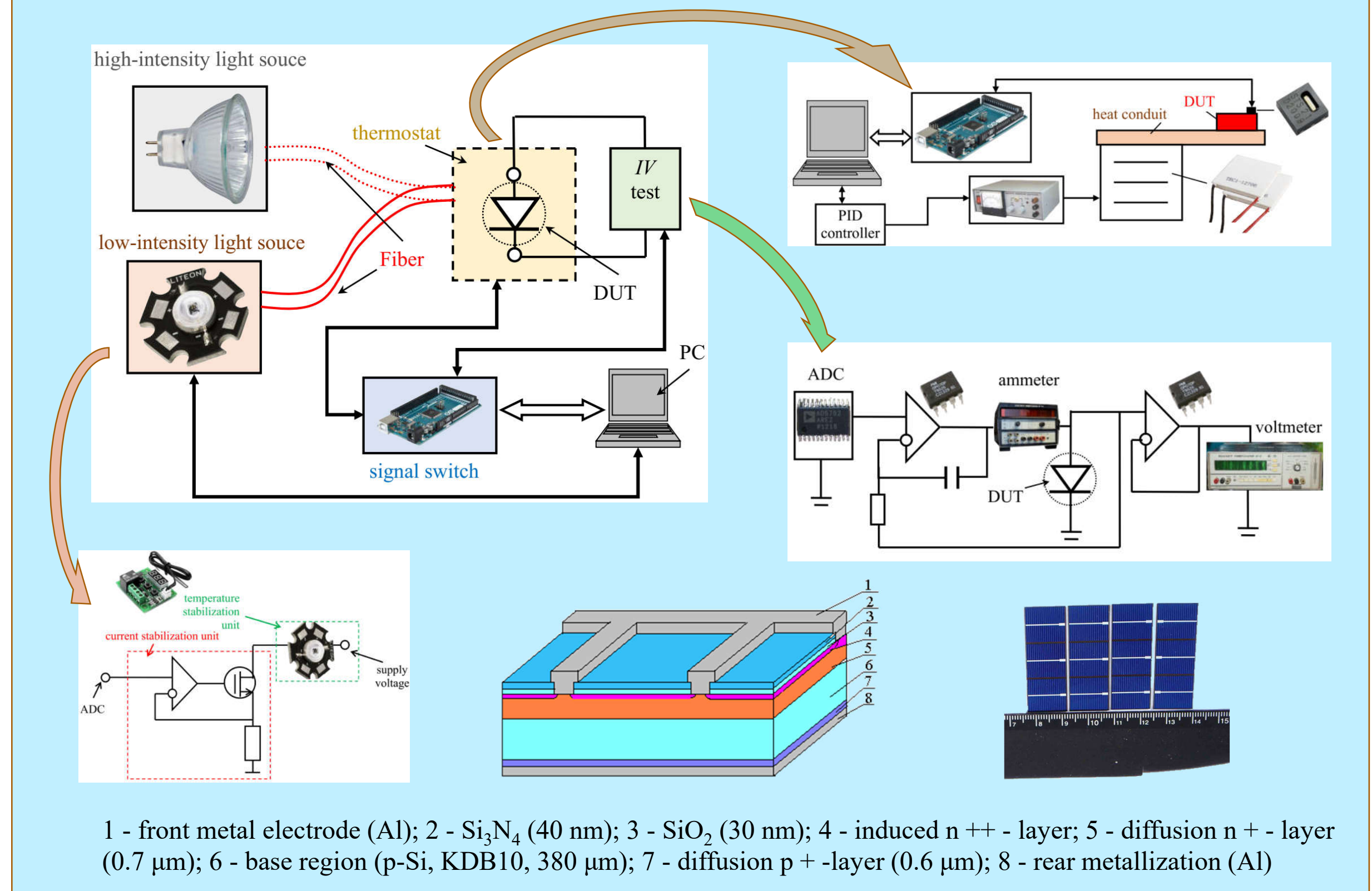
$$\tau_{ass} = \frac{5.7 \cdot 10^5}{N_A} T \exp\left(\frac{E_m}{kT}\right)$$

$$N_{FeB}(t) = N_{Fe,0} - N_{Fe}(t)$$

W_{ph} is the LED irradiance, $N_{Fe,0}$ – iron concentration after illumination, E_m is the Fe_i migration energy, N_A is the doping level.

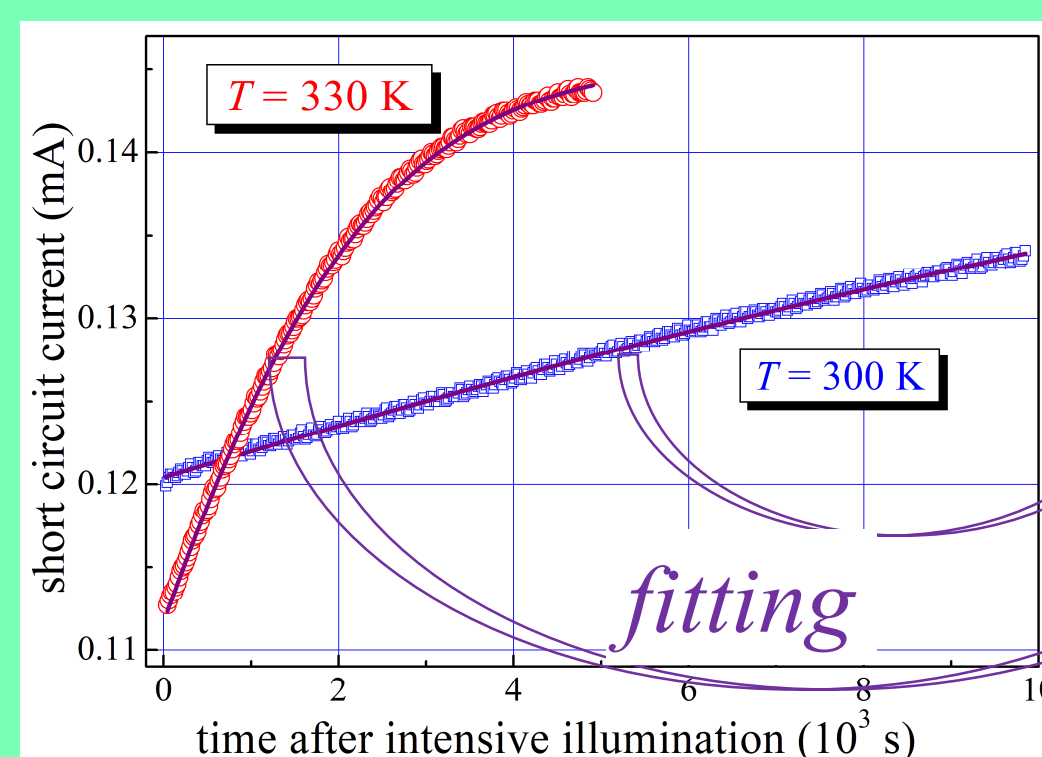
calculated values (green dashed circle) experiment parameters (blue dashed circle)

EXPERIMENTAL SETUP and SAMPLES



RESULTS

Proposed procedure: (i) to dissociate FeB pair (illumination, heating, carrier injection); (ii) to measure kinetic of short circuit current (at monochromatic illumination); (iii) to approximate the measured dependence and extract iron concentration

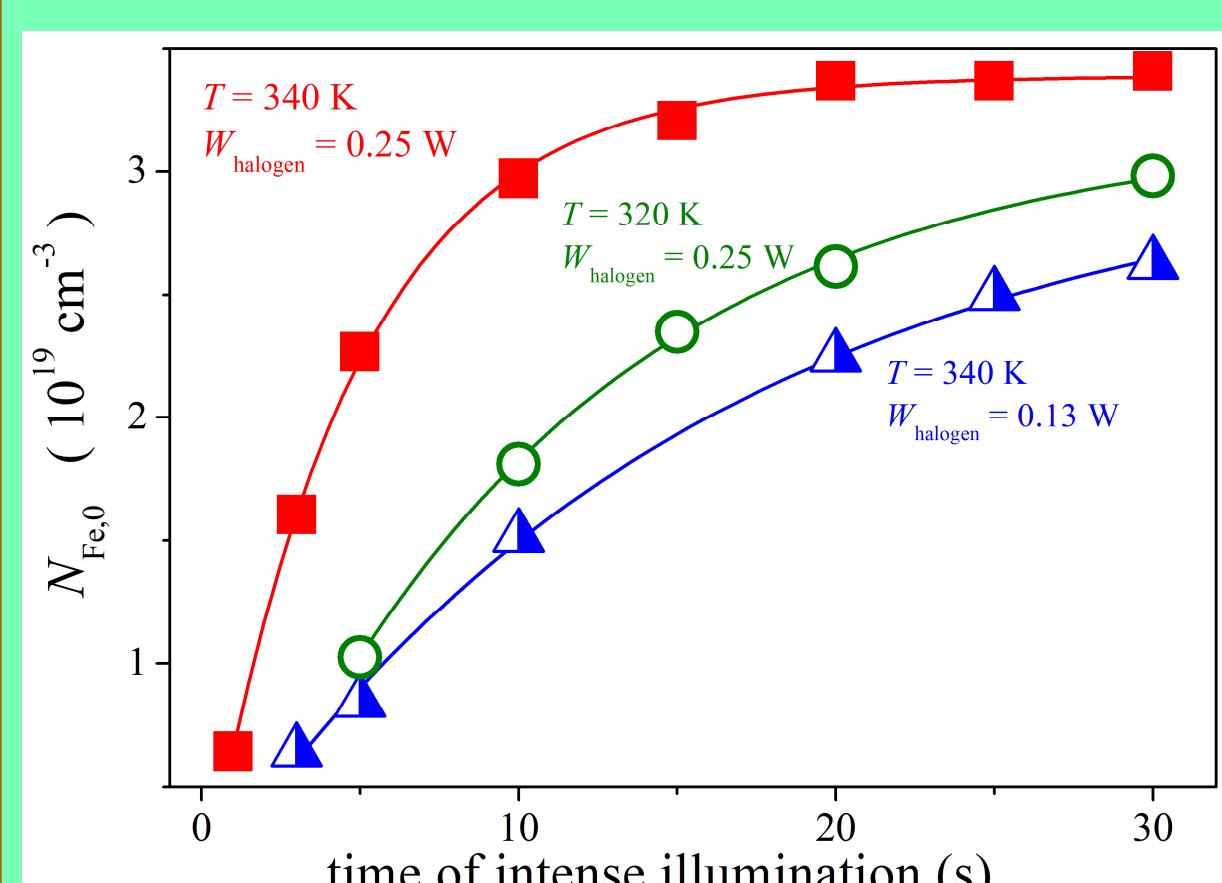


The marks are the experimental results, and the solid lines are the fitted curves.

Cross-validation: the dissociation time (τ_{dis})

(i) proportionate to $(W_{halogen})^2$ [*J.Appl.Phys.* 116 024503]

(ii) decrease approximately twice per 20°C increase [*Appl.Phys.Lett* 63 3044]



$N_{Fe} = 2 \cdot 10^{13} \text{ cm}^{-3}$
 $W_{ph} = 3.2 \cdot 10^{-4} \text{ W}$
 $E_m = 0.655 \text{ eV}$
 $3.1 \cdot 10^{-4} \text{ W}$
 0.66 eV
J. Appl. Phys. 116 024503

T, K	W _{halogen} , W	τ_{diss} , s
340	0.13	16±2
340	0.25	4.6±0.2
320	0.25	11±1

Conclusion. The method to predict iron contamination in silicon solar cell by using kinetic of short circuit current is proposed. These approach envisages the utilization of a simple and widely applicable setup and does not require a much time. The method was validated by studying the temperature and illumination dependences of FeB pair dissociation time.